WDX Studies on Ceramic Diffusion Barrier Layers of Metal Supported SOECs

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1 Introduction

A porous cermet of Y2O3 stabilised ZrO2 (YSZ) and Ni is a commonly used material for the cathode in solid oxide electrolyser cells [1–3]. In metal supported cells (MSCs) from the German Aerospace Center (DLR) in Stuttgart, Germany [4], the Ni-cermet cathode material is directly deposited onto a porous metallic substrate of a Fe–Cr–Plansee alloy (oxide dispersively strengthened PM ODS-alloy) followed by the YSZ-electrolyte and the Sr doped LaMnO3-anode (LSM) (Figure 1). As the Ni cermet is in direct contact with the substrate steel alloy, mutual element diffusion involving Fe, Cr and Ni occurs between the substrate and the electrode causing unintentional chemical and structural changes. In this context, ceramic diffusion barrier layers (DBLs) of doped LaCrO3-type and doped LaMnO3-type perovskite [5] developed by DLR [6, 7] have been integrated between the metal substrate and the cathode (Figure 1) in order to avoid these cell-degrading effects. In general, the DBLs have to ensure gas transport from the metal substrate towards the cathode and to cover the contact points between the particles of the electrode and the substrate to prevent element diffusion. This can be provided either by applying a thick layer (∼50 μm) of certain porosity covering the entire surface of the porous metal substrate [Table 1: vacuum plasma spraying (VPS)-layer cell 2] or by closing the contact spots of the substrate particles which have physical contact with the cathode with a dense and thin (5–10 μm) DBL [Table 1: physical vapour deposition technique (PVD)-layer cell 3] [7]. To quantify the diffusion process and to verify the efficiency of the barrier layers, post mortem investigations on cross-sections of three different electrolysis cells (Table 1) have been performed.

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2 Experimental

The investigated MSCs with circular shape (12.5 cm²) were fabricated by plasma spray technology at DLR Stuttgart [8, 9]. The metal substrate is a 1 mm thick Fe-Cr ferritic steel alloy (Plansee, Austria) which is manufactured by a powder metallurgical process [10]. DBLs were deposited directly onto the substrate either by VPS (cell 2) or by the PVD technique [7] (cell 3), followed by plasma spray deposition of NiO/YSZ under atmospheric conditions (APS). The YSZ electrolyte was applied by VPS, the LSM anode was screen-printed or plasma sprayed onto the electrolyte layer. The cells first were activated in fuel cell mode in order to reduce the NiO to Ni following the electrolysis operation (Table 1).

For scanning electron microscopy (SEM) and electron probe microanalysis (EPMA) pieces of the analysed cells were cut in cross-section geometry and embedded with epoxy resin. A highly fluid resin with an adequate processing time (1 h) was used (Araldite BY158/Aradur 21). As the samples are composites of soft metal parts and hard ceramic material, a resistant resin was used for proper grinding. The resin was infiltrated into the sample first at about 20 mbar, then under over pressure (2 bars) to fill all free pore space of the porous cell parts. After grinding with SiC the samples were subsequently polished with diamond suspension (MetaDi monocrystalline diamond suspension from Buehler) were subsequently polished with diamond suspension down to 0.05 Micron from Buehler). Finally, the sample covering with colloidal silica suspension (Masterprep Polishing suspension 0.05 Micron from Buehler) was covered by a thin C-film to make the surface electrically conductive.

The as-prepared cross-sections were investigated by SEM- and EPMA-technique (Philips XL30 ESEM-FEG and Jeol Superprobe 8800). EPMA is an experimental wavelength dispersive X-ray technique (WDX) to determine chemical compositions on a microstructural level at high accuracy. The measurements are carried out by measuring the energy and intensity distribution of the X-ray signals generated by a focused electron beam. In contrast to energy dispersive spectrometry (EDS), EPMA takes the advantage of the wave nature of photons as specific X-rays are diffracted and isolated according to their wavelength by means of Bragg reflection on an analysing crystal. WDS is performed with an electron probe microanalyzer, which is an adapted scanning electron microscope equipped with several spectrometers for simultaneous measurements of different elements. Since in an EPMA-spectrometer certain characteristic X-ray photons of relevant chemical elements can be selected and isolated from other emitted X-ray photons, the peak-background ratio and the spectral resolution of WDS are much higher in relation to EDS. EDS detectors are collecting all X-ray photons emitted from the sample so that measurements are fast but the accuracy is low compared to WDS analysis. Therefore, the WDX technique has only little peak overlap of characteristic X-rays of similar energy, lower detection limits and therefore a higher accuracy (Figure 2). SEM imaging and two-dimensional X-ray element mappings (EPMA) were done to verify the regularity of the respective barrier layer. Quantitative measurements were carried out by EPMA on metal grains to quantify the Fe, Cr and Ni mass transport due to diffusion-processes during cell operation for cells with and without a DBL. After operation, concentration gradients in the metal grains of the cathode and the substrate of aged cells were determined. Quantitative EPMA measurements were carried out at 25 kV and 3 × 10⁻⁶ A, element mappings at 15 kV and 3 × 10⁻⁸ A.

3 Results and Discussion

Owing to kinetic reasons, the diffusion of Fe, Cr and Ni between the cell electrode and the substrate takes place over the particular metal-phase distribution via solid-state reactions. Diffusion of Fe and Cr occurs over the Ni-toparticles, diffusion of Ni over the FeCr-substrate respectively.

In cell 1, a cell without a DBL, the Ni grains of the cathode are in direct contact with the substrate alloy at the interface [Figures 3(a) and 4]. In this case, our EPMA investigations...
revealed significant mass exchange between the metal substrate and the cathode (Figure 4) after 230 h under electrolysis conditions. A considerable amount of iron and chromium was detected in Ni grains of the electrode. Conversely, Ni was found in the metal substrate alloy material. Quantitative analysis showed that around 17% of the Ni atoms in grains at the interface were substituted by Fe and Cr, converting the Ni phase into a Ni-based alloy. Corresponding to the chemical changes, the oxidation behaviour altered and the electrochemical activity decreased, which resulted in an unintentional decrease in the cell performance. Measurements on the substrate grains showed a distinct decrease in the Cr-content of up to 50 wt.-% due to Cr-loss compared with the virgin steel substrate (initial composition: Fe, 26Cr). The highest Ni concentration measured in the metal substrate is approximately 4 wt.-%, whereas the original ferritic steel alloy is altered at least partially into an austenitic structure [3]. This increases the coefficient of thermal expansion which can cause cracks in the substrate lowering the long-term stability and cell performance.

A possibility to suppress the metal element diffusion in order to avoid the associated structural and chemical changes is the integration of a DBL between the cathode and the substrate. As element diffusion takes place over the contact points between Ni and the alloy grains, closing these diffusion tracks by integrating a barrier layer inhibits the mass transport. Nevertheless, this barrier layer has to be either porous enough to ensure the gas distribution or to be limited spatially to the contact points without influencing the percolative pore-structure of the substrate/electrode interface.

Diffusion was inhibited successfully in cell 2 by an approximately 50 μm thick VPS made LaCrO₃-type perovskite barrier layer [Figure 3(b) and 5]. The quantitative measurements showed that less than 0.4% of the Ni atoms were replaced by Fe and Cr (Figure 5). Equally, the Cr content of the steel substrate decreased only by 20 wt.-%. Both, Ni in the substrate and Fe in the electrode replace less than 0.1% of the primary metal atoms after 230 h of cell operation. Only approximately 0.3 wt.-% Cr was detected in the Ni grains of the cathode of cell 2. Compared to cell 1, the degradation process was significantly suppressed as almost no Fe and Ni diffusion occurred. The source of Cr is either the DBL itself as it is a LaCrO₃-type perovskite or the cell substrate.
The PVD processed DBL of cell 3 has a reduced thickness of less than 5 μm [Figure 3(c) and 6], which is around 1/10th of the VPS processed layer-thickness of cell 2. The Cr content of the steel substrate decreased by approximately 40 wt.-% (Figure 6). Maximal 1.5% of the Ni atoms of the electrode close to the interface were substituted by Fe and Cr after 2,030 h of electrolysis operation. The highest Ni concentration in the substrate is around 0.5 wt.-%. According to the presented quantitative analysis, the degradation process in the long-time study of cell 3 was reduced by factor 10 in relation to cell 1, while the operating time was about 9 times longer.

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Fig. 4 Backscattered electron (BSE) image (left) and element diffusion diagram (right) of the cathode/substrate interface of cell 1 (without a DBL) after 230 h of operation. The diagram corresponds to the arrows in the BSE-image showing significant mass exchange due to element diffusion.

Fig. 5 BSE image (left) and element diffusion diagram (right) of the cathode/DBL/substrate interface of cell 2 (doped LaCrO₃-type VPS DBL) after 230 h of operation. The diagram corresponds to the arrows in the BSE-image. Element diffusion was successfully inhibited by the integrated DBL.

Fig. 6 BSE image (left) and element diffusion diagram (right) of the cathode/DBL/substrate interface of cell 3 (doped LaMnO₃-type PVD DBL) after 2,030 h of electrolysis operation. The diffusion diagram corresponds to the arrows in the BSE-image. Element diffusion was successfully inhibited by the DBL. Note that the PVD-layer is only 5–10 µm thick and is integrated between the Ni/YSZ electrode and the FeCr-substrate.
References


